

U.S. P.T.O. 1449 U.S. Department of Commerce Attorney Docket No.: 1006 Serial No.: 09/706,475
 Patent and Trademark Office
 LIST OF PRIOR ART CITED BY APPLICANT
 Applicant(s): Alexei Pilipetskii et al.
 Filing Date: November 3, 2000 Group: 2633

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| | DOCUMENT NUMBER | | | | | | | | DATE | COUNTRY | CLASS | SUBCLASS | YES | NO |
| <i>Sh</i> | BA | 1 | 0 | 3 | 5 | 6 | 7 | 1 | 9/13/00 | Europe | H04B | 10/18 | | |
| <i>Sh</i> | BB | 2 | 7 | 9 | 0 | 6 | 2 | 5 | 9/8/00 | France | H04B | 10/12 | X* | |
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| | BE | | | | | | | | | | | | | |

(OTHER PRIOR ART, INCLUDING AUTHOR, TITLE, DATE, PERTINENT PAGES, ETC.)

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 CC M. E. Marhic et al., "Optimizing the Location of Dispersion Compensators in Periodically Amplified Fiber Links in the Presence of Third-Order Nonlinear Effects", IEEE Photonics Technology Letters, IEEE Inc., New York, US, vol. 8, no. 1, 1996, pages 145-147.

EXAMINER *Shi K. Li* DATE CONSIDERED *11/6/2003*

EXAMINER: Initial if reference is considered, whether or not citation is in conformance with MPEP 609: Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to application.

* See enclosed copy of U.S. equivalent, U.S. Patent No. 6,324,317